

Application Serial No. 10/516,379
Reply to Office Action of December 12, 2007

RECEIVED
CENTRAL FAX CENTER

JUN 17 2008

PATENT
Docket: CU-3989

Amendments to the Claims

The listing of claims presented below replaces all prior versions, and listings, of claims in the application.

Listing of claims:

1-16. (cancelled)

17. (previously presented) A method for manufacturing[[, the]] a decorative material ~~according to claim 13~~, wherein the ionizing radiation curing resin composition, containing an ionizing radiation curing resin and a delustering silica which is a silica whose surface is treated with a fatty acid based wax, is coated on a base material sheet ~~formed into the luster adjusting resin layer, with no solvent~~, by using a doctor blade and a gravure plate to form a luster adjusting resin layer (on the base material).

18-26. (cancelled)

27. (new) The method for manufacturing a decorative material according to claim 17, wherein the ionizing radiation curing resin composition contains no solvent.

28. (new) The method for manufacturing a decorative material according to claim 17, wherein an amount of the declustering silica contained in the ionizing radiation curing resin composition is in a range of 5 parts by mass to 20 parts by mass to 100 parts by mass of the ionizing radiation curing resin.

29. (new) The method for manufacturing a decorative material according to claim 27, wherein an amount of the declustering silica contained in the ionizing radiation curing resin composition is in a range of 5 parts by mass to 20 parts by mass to 100 parts by mass of the ionizing radiation curing resin.

29. (new) The method for manufacturing a decorative material according to claim 18, wherein the luster adjusting resin layer is formed in pattern on the base material sheet.

Application Serial No. 10/516,379
Reply to Office Action of December 12, 2007

PATENT
Docket: CU-3989

30. (new) The method for manufacturing a decorative material according to claim 19, wherein the luster adjusting resin layer is formed in pattern on the base material sheet.